A three-dimensional coupled fluid-droplet model is developed specifically to characterize the significance of droplet-plasma interaction at atmospheric pressure. The liquid droplet introduces a perturbation in atmospheric pressure plasmas (APP) and under many conditions, the behavior of this perturbation is not clear in APP. In this study, we identify the importance of ionization mechanism for the vaporization of droplets during the interaction. The affect and spatial expansion of vaporization in discharge plasma depend on the flow rate of liquid precursors. Penning ionization is recognized as the leading process along the pulse of evaporating droplets as compared to other ionization processes that explain the relevance of small nitrogen impurities. The influence of different precursors, such as Hexamethyldisiloxane, Tetraethyl orthosilicate and water in an APP is described by contrasting the implication of evaporation process along the pulse of droplets. We validate the numerical simulation by comparison with the experimental observations of droplet size distributions using a laser diffraction particle size analysis technique as a part of atmospheric pressure plasma jet deposition system.

I. INTRODUCTION

In recent times, the functions of non-equilibrium atmospheric pressure plasmas are appreciated as an attractive and a promising source for numerous industrial and medical science applications, such as surface modification and etching of polymers [1], ozone generation [2], food processing [3], plasma-polymerized thin film [4], sterilization [5], coating of biomedical implants [6], cell detachment and tissue engineering [7] under several different operating conditions and chamber composition geometries. Generally, the behavior of a helium atmospheric pressure plasma is sharply modified by the presence of impurities in the form of gas, liquid and solid in which the interacting mechanism of solid and liquid phases are more complex than gas impurities, and which requires a detailed physical understanding of their phase transformations during interaction with plasma [8, 9] for various applications. In combustion applications, the technique for direct-injection of liquid precursors into gas mixture has been efficiently applied to achieve the desired output for the specific processes [10, 11] comprising of two-phase flow. The desired surface morphology of deposition coatings can be obtained by modulating monomer flow rates in atmospheric pressure plasma jets, which discussed the various interesting mechanisms such as, saturation, nucleation and possibility of solidification in two-phase flow [12].
The introduction of specific amounts of precursor and gas flow rates have been recognized as the active controller to obtain the required features of surface deposition, while the mechanism of interaction relies upon the chemical properties of gas mixture as well as liquid precursors [13, 14]. Fluid models are considered as satisfactory for the investigation of the physical phenomena involving stagnant and flowing plasmas, however, the data for the mobility and diffusivity of discharge species, excitation, ionization and other inelastic collision rate coefficients are calculated from the swarm experiments of concerned gas mixtures [15]. Perhaps, the accuracy of numerical simulations depends on several parameters, such as, mesh geometry, suitable algorithm and operating conditions, but the coherence among them is essential to obtain the effective outcomes for the specific experiment [16]. During the droplet-plasma interaction, the volumetric effect of external forces of the discharge plasma has significant impact on droplets during the transport in the channel of plasma stream [17]. The charging of droplets is recognized as an important factor to alter the ultimate characteristics of plasma deposition because of sheath formation around the droplets [18] and it modifies the distribution of plasma.

In this study, the complex interaction between the liquid precursor droplets and plasma are explored by the integration of a fluid and stochastic liquid droplet model in which the two models are working at different time scales, but the average values of electric field obtained from the plasma are passed down in the numerical solution of mass, momentum and energy equations for the liquid and gas phases. This produces a consistent updating of both models through the coupling source terms during the transport of two-phase flow. The real time description of droplet-plasma interaction can be possible only by using a three-dimensional modelling approach because it explains in detail the precise aspects of liquid droplets during interaction with discharge species of plasma along the radial, axial and azimuthal directions. It is interesting to describe in detail the evolving conditions under which the phase shifting operation of liquid droplets transforms into vapours in case of various liquid precursors.

II. THREE DIMENSIONAL COUPLED FLUID-DROPLET MODEL

In this section, a brief mathematical description of three-dimensional coupled fluid-droplet model is provided for the geometry of the PlasmaStream atmospheric pressure jet deposition system [19] under similar operating and boundary conditions. For the liquid phase, it is handled by applying the Lagrangian method and an appropriate sample of droplets is introduced by utilizing x-squared distribution (\( r_d \) and \( r_{\text{mean}} \) are the radius and mean radius of droplets. For the gas phase, the Eulerian approach provides satisfactory results for He-N\(_2\) mixture. The Poisson's equation is solved numerically for the
evaluation of electric potential by assuming an asymmetric electrode geometry of the PlasmaStream system [20]. The set of equations is applied to the modelling of plasma gas is

\[(1 - 4)\]

where the nomenclature of variables of the above set of equations is presented along with description in table 3. The coupling source terms \((S, S_\text{sp} \text{ and } S_\text{E})\) bind two models, which are included in the fluid model equations of mass density, momentum and energy of APP and droplet Eqs. (1 - 4). A stochastic liquid droplet model [21] is employed for the droplet-droplet mutual interactions, which involves the major collision interactions, such as grazing and coalescence of droplets. The Implicit Continuous Eulerian (ICE) method [22] is used in the present simulation study, which has been considered as decent and useful for the gas flows of any Mach number, and for the evaluation of terms involving momentum exchange between two phase flow. In case of plasma species, the kinetics of particles \((e^-, \text{He}^+, \text{He}_2^+, \text{N}_2^+, \text{He}^* \text{ and } \text{He}_2^*)\) are calculated by the numerical solution of the time-dependent continuity equation written as

\[(5)\]

where \(n_\text{sp}, \text{ and } S_\text{sp}\) represent the species density, drift-diffusion flux and source term for the production and annihilation of discharge species in distinctive chemical reactions described in [23] for He-\(\text{N}_2\) gas mixture. The diffusion coefficient is evaluated by using the Einstein relation \((D_\text{sp} = \mu_\text{sp}k_B T_\text{sp}/q_\text{sp})\) for discharge species. The transport and reaction rate coefficients of electron impact chemical reactions are reliant on the electron mean energy, which are adjusted at every time step in the plasma model and operated as a strong coupling factor between the two-phase flow. The electron mean energy \(\phi\) is evaluated by using the electron energy density balance,

\[(6)\]

where \(n_e\) is the electron density and is the drift-diffusion flux in the electron energy density equation multiplying by a factor of 5/3. \(S_e\) is the energy source term comprising of joule heating, electron energy losses and the implicit correction term, and the further explanation of this term is available in [24]. The alternating direction implicit (ADI) solver [25] is used for the numerical solution of the particle balance equation of discharge species and electron energy density equations. In order to evaluate the electric field, the Poisson's equation is coupled with the plasma fluid model for the estimation of electric field \(\vec{E}\), which is expressed as

\[(7)\]

where \(\varepsilon_0\) is the permittivity of the free space and the product \((q_\omega n_\text{sp})\) represents the space charge density. So, the electric field strengths are calculated from the gradient of the electric potential along \(r, \theta\) and \(z\) directions as , and . The numerical solution of Poisson's equation is obtained by applying successive over relaxation (SOR) method [26] in which the rapid convergence attains through the proper choice of overrelaxation parameter \((\omega)\) existing in the interval \((1.5 < \omega < 2)\). The local field
approximation implements to the ionic species in which the transport and reaction rate coefficients are expressed as the function of the electric field, and the effective electric field [27] is determined for the transport of ions. As the droplets drag in the plasma chamber, the rate of change of transient position \((x_p)\), velocity \((u_p)\), radius \((r_p)\) and temperature \((T_p)\) of droplets in the parcels are evaluated by the set of equations discussed in [10, 14].

. Stochastic Liquid Droplet Model

A distinct \(x\)-squared distribution of droplets in various parcels is introduced from the central position in the computational grid along the radial, axial and azimuthal coordinate axes. The properties of droplets are identical in each parcel and the collisions only occur between different parcels. The collision frequency \((\nu_c)\) of a collector droplet with other droplets is determined by

\[
\nu_c = \frac{4\pi r_{col} r_{con}}{V_{ijk} \Delta t}
\]

where \(r_{col}\) and \(r_{con}\) are radii of the collector and contributor droplets respectively, \(\Delta t\) is the computational time step for the Lagrangian approach. The probability of missing collision can be revealed by the following formula as, where \(\Delta t_i\) is the computational time step for the Lagrangian approach. The collision and critical impact parameters \((b, b_{cr})\) respectively are defined for the dynamics of droplets by the following relations as

\[
E_{coal} = \frac{1}{2} - \frac{2.4}{\gamma^2} - \gamma + \frac{1}{\gamma^3} - \frac{r_{con}}{r_{col}}
\]

where \(E_{coal}\) is the coalescence efficiency and defined as. The function \(\xi(\gamma)\) is, for simplicity, approximated by \([10]\) as \(\xi(\gamma) = \gamma^3 - 2.4 \gamma^2 - \gamma\) and \(\gamma = r_{con}/r_{col}\). If \(b \geq b_{cr}\), then the result of a collision is designated as grazing, such collisions appears just after injection of droplet pulse. In case of grazing collision, the collectors and droplets in the parcels collide in such a way that they retain their radii and temperatures, but the velocities are altered after this interaction. If \(b < b_{cr}\) the droplets coalesce to form a new droplet with greater radii during downward displacement in the plasma chamber. The values of constant parameters, such as molecular weight, specific heat of liquid and vapour phases, thermal conductivity, dynamic viscosity, latent heat of vaporization, mass density and surface tension of liquid precursors are collected from the source \([28]\). In coupled fluid-droplet model, the numerous variables and constants are employed in the set of Eqs. (1 - 10), which are expressed in detail in table 3.

B. Initial and Boundary Conditions

We consider a chamber geometry as discussed in \([20]\) for the PlasmaStream atmospheric pressure jet deposition system in which the gas flow is introduced at two specific positions with gas flow rates \((Q_1\) and \(Q_2\)) separated by a pin metal electrode, while the nebulizer droplets are injected from the central location \((B)\) with a flow rate \(Q_3\) and interact with APP in the He-N,
gas mixture. The different types of precursor droplets in parcels are introduced through the central location of APP along the He-N$_2$ (99 % He and 1 % N$_2$) carrier gas. The major details of initial and boundary conditions are described in table 1 for the variables of the fluid-droplet model during two-phase flow.

Table 1. Initial and boundary conditions for Fluid-Droplet Model (FD3d)

<table>
<thead>
<tr>
<th>Inlet (z = 0)</th>
<th>Centerline (r = 0)</th>
<th>Angular axis (θ = 0)</th>
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<table>
<thead>
<tr>
<th>Exit (z = L)</th>
<th>Glass wall (z = R$_0$)</th>
<th>Angular axis (θ = θ$_0$)</th>
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</table>

Here $u$, $v$ and $w$ are the radial, axial and swirl velocities of gas mixture. For a solid pin electrode and a grounded substrate, the flux of the heavy charged particle species, electron, neutrals and electron energy density at the solid boundaries are computed by using the modified boundary conditions in [29, 30] during the alternate cycles of oscillating sinusoidal potential. The average thermal velocities of the discharge species are evaluated using. The evaluation of electron mobilities as well as reaction rate coefficients of excitation and ionization processes are obtained by using Boltzmann solver (BOLSIG+) [31]. For the coupled model, the two different time steps ($\Delta t_1$, $\Delta t_2$) are used to control the two-phase flow in which the Courant–Friedrichs–Lewy (CFL) condition [15] is applied for the evaluation of the time step in case of discharge plasma, whereas the liquid and gas phases have a higher value of the time step ($\Delta t_1$) than the plasma time step ($\Delta t_2$) in this simulation study.

### III SPATIO-TEMPORAL BEHAVIOR OF DROPLET-PLASMA INTERACTION

In complex geometries, the numerical simulation tools are preferred to experiments for the description of the interesting details of droplet-plasma interaction if the functioning conditions of the experiment precisely implement in the mathematical model. We consider several input operating parameters (axial length and diameter of experimental chamber, sinusoidal external imposed potential, driving frequency, operating pressure and temperature of gas, flow dynamics of precursors and gas, liquid precursor characteristics, such as radius, temperature, initial injection velocity, and appropriate size distribution of droplets) of the experiment [12] in three-dimensional fluid-droplet model to predict the complicated features of two-phase flow. In the first case, a pulse of water precursor droplets is introduced from the central location into the plasma chamber existing in the size domain (2 $\mu$m $\leq r_d \leq$ 13 $\mu$m) from the nebulizer. When the droplets interact with discharge plasma, they experience
electrical, aerodynamic drag, internal viscous (\(\mu\)) and gravitational forces during downward displacement in the PlasmaStream system containing He-N\(_2\) discharge plasma. During interaction, the electrons and ions rush towards the surface of droplets, however, the droplets acquire negative potential on their surface due to greater mobility of electrons. The electrons around the water droplets perform an important role in the heating because of the non-equilibrium nature of discharge plasma in which the electrons and ions are present at two different temperatures. The electron mean energy lies in the range of 0.1 - 5.0 eV, but the ionic species have similar temperature of gas mixture that is consistently updated from the evaluation of enthalpy of gas mixture as mentioned in Eq. (3). This means that the electrons are acting as a source of heat provider for the droplets and ultimately enhance the vaporization of droplets in discharge plasma. These interactive mechanisms will be tested by the application of various liquid droplets in order to describe the physical understanding between two phase flow.

![FIG. 1. Temporal evolution of mean radius, mean temperature, mean axial velocity and mean vapour species density for the entire pulse of water droplets at flow rate = 10 \(\mu\)L/min, gas flow rate = 5 L/min, \(f = 20\) kHz and \(V_0 = -13.5\) kV.](image)

FIG. 1 shows modelling results of the average temporal profiles of radius, temperature, axial velocity and vapour species density of water droplets during the interaction between the liquid and discharge plasma. It is seen from the distribution of mean radius that the rate of change of droplet radii is significantly smaller in the beginning, i.e., during the first 1 ms, and becomes expeditious as they attain the stationary state that is clearly verified from the mean profile of axial velocity of droplets as represented with a dash dotted blue line. The sharp decline in the mean radius of droplets provides a clear
indication of strong evaporation in discharge plasma and it is confirmed from the increase in the temperature of water droplets in the parcels as illustrated by the green dotted line. Since the evaporation rate of droplets increases and its residue vapour represents another species called as vapour species density as displayed by the black dashed line in FIG. 1. The vapour species density is calculated by the product of vapour species mass fraction ($Y$) and mass density of operating gas ($\rho_g$). This results as the enhancing of coupling between two phases during downward convection of liquid droplets in discharge plasma. The vapour species density increases until to steady-state just before the phase transformation of the entire pulse of droplets. During the downward drag, the local temperature of APP strongly falls in the surrounding volume of the droplet's pulse due to vaporization and it expands with the passage of time. The small spikes as shown with a pointed arrow in the profile of the mean radius of droplets in FIG. 1 (for times greater than 7 ms) correspond to the rapid phase transformation of liquid droplets into vapours after obtaining the minimum radius due to the absorption of sufficient energy from the discharge plasma. The corresponding parcel is removed from the size distribution of droplets by modifying the entire size distribution of droplets afterwards. Therefore, the dynamic behavior of droplets pulse in APP is clearly reflected from the mean profiles of various parameters as shown in FIG. 1 indicating the role of complex interaction between two-phase flow.

IV. INFLUENCE OF HMDSO PRECURSOR FLOW RATES

Because different kinds of liquid precursors are used for the treatment of surface depositions in the atmospheric pressure plasmas using He-N$_2$ gas mixtures, the effectiveness of HMDSO precursor droplets is analyzed by employing various flow rates of precursor existing in the domain ($1 \leq r_d \leq 6 \mu m$) under similar constraints. It is observed from the numerical simulations of HMDSO droplets that the duration of evaporation for the entire pulse of droplets is less than 1 ms in case of 10 $\mu$L/min, and the considered duration consecutively magnifies with an increment in the precursor flow rate for the considered distribution of droplets.
FIG. 2. Spatial distribution of vapour species density under particular HMDSO precursor flow rates (10, 50 and 100 µL/min) in He-N₂ APP at a gas flow rate = 5 L/min, f = 20 kHz and V₀ = -13.5 kV.

FIG. 2 (a, b, c) illustrates the slice distributions of vapour species density at the specific locations of plasma chamber in order to elucidate the importance of vaporization of droplets under the above-mentioned precursor flow rates, such as at 10, 50 and 100 µL/min. As the HMDSO is volatile [12] in nature in He-N₂ gas mixture, it evaporates so quickly forming a constricted carrier along the pulse of droplets. The channel of evaporation broadens continuously during the downward movement and it transfers its uniform ramification on the deposition of the substrate surface. It is observed from the spatial slice distributions that the effected volume in APP is amplified with an increment in the precursor flow rates from 10 to 100 µL/min as shown in FIG. 2 (a, b, c) and resulted as the local cooling of gas near the vaporizing liquid droplets. The local cooling acts as a further disturbance in the discharge plasma, which depresses adequately the rate of evaporation near the present vaporizing droplets after obtaining the saturation condition. The appearance of local cooling is not highly probable at a small precursor flow rate (≤ 10 µL/min), but it can become significant at higher precursor flow rates (> 100 µL/min). Subsequently, the effect of higher precursor flow rate occurs as a wider volume of vapour species density in APP than small flow rates as displayed in FIG. 2 (c), which supports the development of saturation mechanism. This is verified by comparing the numerical values of vapour species density that amplifies from the lower to higher as (0.045 × 10⁻³, 0.09 × 10⁻³ and 0.12 × 10⁻³ g/cm³) at 10, 50 and 100 µL/min. Therefore, the higher amount of precursor flow rate exaggerates the cooling in APP and impedes the process of further evaporation during the downward flight of droplets.

Under the implication of the concerned flow rates of precursors, the entire pulse of liquid droplets is evaporated completely within the residence time of the gas mixture. Before phase transformation of liquid precursors into vapours, the radii of droplets survive in the nanometer domain. Since the distribution of parcels contains a large number of radii of droplets, every individual droplet experiences the gravitational and electrical attraction in APP. The magnitudes of these downward attractive pulls on the HMDSO droplets reply upon the radii of droplets. This means that the droplets are attracted downwards strongly in case of higher precursor flow rate than small precursor flow rates. Thus the higher radii of droplets are crossed rapidly from the plasma chamber, which can possibly initiate a seed for the development of non-uniform deposition on the substrate surface.

V. BEHAVIOR OF PENNING IONIZATION

To explore the behavior of kinetics of charged particles between two-phase flow, the active behavior of discharge plasma is investigated by analyzing the ionization rates along the pulse of evaporating droplets in He-N₂ and He-Air gas mixtures. In He-N₂ gas, the Penning ionization is dominant due to involvement of molecular nitrogen participants, but in He-Air gas mixture, it is a combination of molecular nitrogen, atomic and molecular oxygen and water molecules. In the PlasmaStream
system, the ionization is significantly stronger near the pin cathode and grounded substrate during the alternate peaks of discharge current pulse. The averaging of ionization rates for the entire chamber is not useful to explain the description of droplet-plasma interaction in the atmospheric pressure plasmas. Here, the averaging is performed by ignoring the volume near the cathode and grounded electrodes, which reflects the prominent aspects of interaction between the droplets and APP. Although, the nitrogen molecules (Penning impurities) have smaller ionization potential than helium atoms, they strongly interact with metastables and generate ionization along the pulse of evaporating droplets and the same set of chemical reactions is employed in the present simulation study as discussed in [23]. We now compare the ionization rates produced by the influence of direct ionization (DI), Penning ionization (PI) and stepwise ionization (SI) in the bulk of APP.

Fig. 3. Temporal evolution of rates for the Direct ionization, Penning ionization and Stepwise ionization around the pulse of droplets using HMDSO precursor droplets at flow rate = 100 µL/min and gas flow rate = 5 L/min, \( V_0 = -13.5 \text{ kV} \) in He-N\(_2\) and He-Air gas mixtures.

FIG. 3. contrasts the temporal profiles of ionization rates for the major mechanisms occurring in the bulk of APP with small gas impurities. It is clear from the values of various ionization rates that PI is recognized as extremely important during the discharge current pulses due to the expressive contribution of gas impurities at atmospheric pressure as represented with the black solid circle and plane solid lines (a, a'). PI is dominant in He-air gas mixture than He-N\(_2\), which is appeared due to
the effect of air as impurity in APP in the former process. In He-N$_2$ gas mixture, the asymmetrical pattern of ionization rates is clearly observed from the plane lines (a', b', c'), but this asymmetry is reduced in case of He-Air gas mixture. This happens due to the effect of PI of multiple impurities enhancing the rate of evaporation along the pulse of droplets that show the dynamic modifications in the sheath potential around the pulse of droplets. When the droplets are charged in the discharge plasma, the electrostatic attraction from the substrate sheath potential as well as gravitational pull strongly attracts the liquid droplets (> 10 µL/min). This accelerates the droplets, but the magnitude of acceleration depends on the radii of droplets. It is seen from the numerical simulations that the higher radii of droplets are passed quickly from the plasma channel by partially contributing to the overall evaporation process. The SI mechanism is weaker than PI and DI processes and it also performs an important role to destroy the metastables in order to maintain the stability of discharge plasma. Due to substantial impact of PI, the molecular nitrogen, atomic and molecular oxygen and water ions are prevalent along the pulse of droplets as compared to the atomic and molecular helium ions. The atomic helium ions are immediately transferred to molecular helium ions through the channel of three body chemical reaction that are further converted into molecular nitrogen ions by using the path of charge transfer mechanism.

Near the cathode and grounded substrate, the DI performs an assertive role than PI and SI mechanisms, which is opposite to the role of these mechanisms around the pulse of droplets as shown in FIG 3 (b, b'). This occurs by the primary contribution of small impurities in pure helium gas indicating in the gap spacing around the pulse of droplets as shown in FIG. 2. Since the density of electrons and ions increases after the evaporation of droplets in APP, the remaining droplets evaporate more quickly as the kinetics of charged particles are enhanced by the evaporation of droplets. This is a three step process, i) the electrons coagulate around the droplets heating them to evaporate, ii) the density of gas mixture increases by the conversion of the liquid phase of droplet into vapour species phase as another species, iii) the rate of ionization is amplified around the remaining droplets, and this process consistently going on until the entire pulse of droplets evaporate into vapour species. So, this is very important to develop an equilibrium for the evaporation of entire pulses of droplets during the surface coating to avoid any kind of mechanism, like nucleation in APP. From the above understanding, it is evident that the evaporation process is continuously updated by the leading contribution of various ionization mechanisms (PI, DI and SI) that can be authenticated from the temporal profiles of ionization rates from 600 to 700 µsec.

VI. EFFECT OF HMDSO, TEOS AND WATER PRECURSORS
FIG. 4. Volumetric spatial profiles of vapour species and electron density, and slice distribution of neutral gas species density for different precursors (a, a’) HMDSO, (b, b’) TEOS and (c, c’) water for the precursor flow rate = 100 µL/min, gas flow rate = 5 L/min, f = 20 kHz and \( V_0 = -13.5 \, \text{kV} \).

In order to distinguish the behavior of precursor interaction with discharge plasma, a comparison of the electron, vapour species and neutral gas species densities is performed for the following liquid precursors, such as HMDSO, TEOS and water during the positive peak of the discharge current density after 2 ms as shown in FIG 4. These precursors have atypical physical and chemical properties from one another, which help us to categorize the significance of interactive performance during the downward fall in APP. The magnitudes of electron (red layer) and vapour species density (green layer) for HMDSO precursor are significantly greater than TEOS and water as depicted in FIG. 4 (a - c) because of the intense rate of evaporation and, it is occurring due to the lower surface tension and dynamic viscosity of HMDSO precursor as represented in table 2. The small radii of liquid droplets are quickly converted into vapours by absorbing sufficient energy from the discharge plasma that further amplifies the neutral gas species density through the phase shifting of precursors. In case of
HMDSO liquid precursor, the development of vapour species density (green layer) along the passage of droplets is confined to smaller volume than TEOS and water due to robust rate of evaporation and rapid phase shifting of liquid droplets into vapours. This forms a prominent conductive channel in APP and its strength depends on the rate of evaporation. It is seen from the numerical values of vapour species and electron densities that the HMDSO forms a high density channel of conduction than TEOS and water precursors due to the presence of a smaller number of droplets in discharge plasma as shown in FIG. 4 (a - c).

Now the development of uniform surface deposition is more probable by applying the volatile liquid precursors in helium discharge plasma, which dissolve rapidly like HMDSO as clearly demonstrated in FIG. 4 indicating different parameters during interaction. For water droplets, this situation does not arise due to the sluggish rate of evaporation, which ultimately causes the droplets to smash on the substrate surface. The inert gas species density is increased by absorbing the residue of evaporation that illustrates with slice distributions in the PlasmaStream system for HMDSO, TEOS and water. This means that the number of droplets is greater for TEOS than HMDSO expressing the weak rate of evaporation due to greater surface tension and dynamic viscosity of TEOS. The ionization activities in discharge plasma are functionally dependent on the vaporization of droplets, which can verify with the values of electron density shifting from HMDSO to water as (~ 4.7 × 10\(^{11}\), 3.6 × 10\(^{11}\), 3.2 × 10\(^{11}\) cm\(^{-3}\)). The chemical formulas for the concerned precursors in table 2 exhibit that the bonding patterns are different between their atoms and molecules. The rate of evaporation is small for the water molecules due to the existence of hydrogen bonding that have stronger intermolecular forces between their atoms and molecules [32] and ultimately enhance the life time of water molecules as compared to other precursors in APP. These characteristics of water molecules are diverse significantly than other precursors, such as HMDSO and TEOS, which can be confirmed from the FD3d modelling outcomes in FIG. 4. So, there are greater chances of crashing of higher radii of water droplets on the substrate surface due to small rate of evaporation. The density of neutral gas is continuously reduced from HMDSO to TEOS and water (0.27, 0.21, 0.18 × 10\(^{-3}\) g/cm\(^{-3}\)), which illustrates with the magnitudes of the slice distributions as presented in FIG. 4 (a' - c'). These numerical simulations clearly indicate the consequences of three distinct precursors for plasma coating depositions in APP.

<table>
<thead>
<tr>
<th>Table 2. Variables used in Fluid-droplet model (FD3d)</th>
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<tbody>
<tr>
<td>Liquid Precursors</td>
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<tr>
<td>-------------------</td>
</tr>
<tr>
<td>Water (H(_2)O)</td>
</tr>
<tr>
<td>TEOS (C(<em>8)H(</em>{20})O(_4)Si)</td>
</tr>
</tbody>
</table>
VII. EXPERIMENTAL COMPARISON OF FLUID-DROPLET MODEL AND EXPERIMENT

FIG. 5. Droplet size distributions for HMDSO liquid droplets using Fluid-droplet model (a) and Experimental measurements (b) in He-N$_2$ APP at a precursor flow rate = 100 µL/min, gas flow rate = 5 L/min, $f = 20$ kHz and $V_0 = 13.5$ kV.

To validate the fluid-droplet modelling results, it is imperative to do a comparison with the experimental observations measured using an additional arrangement of laser diffraction particle size analysis technique with the PlasmaStream atmospheric pressure jet deposition system. We insert a pulse of HMDSO droplets in the size domain ($1 \leq r_d \leq 6$ µm) in APP for the present case. It has been observed from the numerical simulations that the mutual interactions between the droplets, such as grazing and coalescence heavily depend on the initial injection velocity discussed in [20]. The droplets acquire a steady state during the downward displacement in the plasma chamber, but the mutual interactions are very important at higher precursors flow rates (> 100 µL/min). Since the experimental conditions are fully implemented in the fluid-droplet model, the initial injection velocity in the present simulation case is $1.0 \times 10^3$ cm s$^{-1}$. If the distribution of droplet's pulse is effected by the mutual interaction between them, it certainly modifies the properties of discharge plasma and has strong implications on the deposition of the substrate surface. When the pulse of droplets drifts downward during interaction with discharge plasma, the radii of droplets continuously shrink with evaporation process shifting the peak of size distribution to the lower domain ($2 \leq r_d \leq 4$ µm). It is evident from the rapid contracting domain of the mean radius of the droplets that the HMDSO precursor is qualified as a fickle because of having smaller values of surface tension, dynamic viscosity and mass density than other liquid precursors, such as TEOS and water.

Figure. 5 (a, b) shows the good agreement between the size distribution obtained from the fluid-droplet model and the stationary experimental measurements of droplets. This clearly indicates that the evaporation is the prime mechanism during droplet-plasma interaction for the specific distribution of droplets. Since the laser diffraction imaging lens arrangement has the limiting resolution for the experimental observations of droplets and it can only capture the minimum possible value of
radius as 500 nm, but the fluid-droplet model provides the information about the minimum possible size of droplets acquired just before the phase transformation. The experimental size distributions are recorded in two different experiments to evaluate the average size distribution of droplets in the plasma chamber. Due to consistent influence of the evaporation process for the pulse of HMDSO precursor, the radii of droplets are shifted into the nanometer range and their typical values lie in the domain \(30 < r_d \leq 100 \text{ nm}\) just before the phase transformation as represented in FIG. 5 (a). It is observed from the numerical simulations that the minimum possible value of droplets is altered for different liquid precursors just before the phase transformation depending on the physical and chemical characteristics. The droplets are evaporated into vapour species after accessing sufficient energy for the phase transition that ultimately updates the structure of He-N\(_2\) APP. Consequently, the physical description of complex interaction between the liquid droplets and plasma is characterized by elucidating the spatio-temporal distributions in three-dimensional space that are validated with the experimental and simulation comparison.

VIII. CONCLUSIONS

We have investigated the spatio-temporal characteristics of droplet-plasma interaction by using a three-dimensional integrated fluid-droplet (FD3d) model in a He-N\(_2\) gas mixture. The behavior of evaporation during interaction between two-phase flow has been explored by providing the temporal profiles of droplets that justify the dynamic modification in the structure of APP. Due to the strong domination of nitrogen impurities, the production of electrons through Penning ionization becomes greater than other ionization mechanisms around the pulse of droplets in the plasma chamber, which is described by the progressive profiles of liquid and plasma parameters. We analyzed the effect of various precursor flow rates (10, 50 and 100 µL/min) of HMDSO in order to contrast the significance of the evaporation process under similar operating conditions. Further, the influence of different precursors is distinguished by exploring the volumetric and slice distributions of electrons, vapour and neutral gas species densities, which show that the rate of evaporation is significantly stronger for HMDSO than TEOS and water precursor droplets in APP. Finally, the fluid-droplet modelling results are validated by comparing with experimental observations to provide the authenticity of numerical modelling results.

Table 3: Variables in Fluid-Droplet Model (FD3d)

<table>
<thead>
<tr>
<th>Symbols</th>
<th>Physical Description</th>
</tr>
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<tbody>
<tr>
<td>(C_p)</td>
<td>Specific heat at constant pressure</td>
</tr>
<tr>
<td></td>
<td>Position of droplets in parcels</td>
</tr>
<tr>
<td></td>
<td>Velocity of droplets in parcels</td>
</tr>
<tr>
<td></td>
<td>Velocity of gas with fluctuations</td>
</tr>
<tr>
<td>(\rho)</td>
<td>Density of liquid precursors</td>
</tr>
</tbody>
</table>
\( k_B \)  
\( g \)  
\( R \)  
\( c \)  
\( D \)  
\( c_p \), \( c_l \)  
\( T \)  
\( P_g = \rho_g R T_g (Y_v / W_v + Y_i / W_i) \)  
\( h_g = (c_p Y_v + c_p Y_i) T_g = c_{pg} T_g \)  
\( \lambda \)  
\( \Pr = \mu g c_p g / \lambda g \)  
\( h_l(T_d) = C_{pv} T_d - L(T_d) \)  
\( S, SM \) and \( SE \)  
\( \mu_p, T_p \) and \( q_p \)  
\( \rho_{pv}, P, \Gamma_{pv}, k_{pv}, h, D_{AB}, Y \) and \( S \)  

Boltzmann constant  
Gravitational constant  
Universal gas constant  
\( c_v \) is used in the calculation of drag coefficient  
Reynolds number of droplets  
Forces acting on the droplets  
Viscosity of gas  
and \( T_s \) are the average and local gas temperatures  
Nusselt number of gas and liquid  
Liquid vapour mass fraction of the surface of droplet and inside APP  
Heat conductivity of gas  
Gas-phase Prandtl number and liquid at constant pressure  
Specific heat of gas  
Surface temperature of droplet  
Equation of state  
Equation of state  
Molecular weight of liquid and inert gas species  
Specific heat of vapour species at constant pressure  
Enthalpy of liquid droplets  
Source terms for the mass transfer, momentum transfer and gas enthalpy, and details present in [10]  
X-squared distribution function, \( r_d \) and \( n_d \) are the radius and number-averaged droplet radius for initial distribution  
Mobility, temperature and charge on discharge species of plasma  
Represent the gas density, velocity of gas, pressure, momentum, thermal conductivity, joule heating, electric field, enthalpy, diffusion coefficient, vapour species mass fraction and various source terms in the set of Eqs. (1 - 4).

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X. REFERENCES


